

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	2	"20050267253"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/20 19:49
L4	8	pores (nm or nanometer) SOCH	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/20 19:52
L5	15	pores (nm or nanometer) SOCH	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2008/12/20 19:56
L6	15	pores (nm or nanometer) SOCH	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2008/12/20 19:57
L7	8947	pores (nm or nanometer) porous	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2008/12/20 19:57
L8	32	pores (nm or nanometer) porous near insulat\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	WITH	ON	2008/12/20 19:57
L9	0	pores (nm or nanometer) porous near insulat\$3 an siloxane	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	WITH	ON	2008/12/20 20:01
L10	8521603	d	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	WITH	ON	2008/12/20 20:01
L11	14	pores (nm or nanometer) porous near insulat\$3 and siloxane	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	WITH	ON	2008/12/20 20:01
L12	0	pores (nm or nanometer) porous near insulat\$3 and cyclicsiloxane	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	WITH	ON	2008/12/20 20:02

L13	2	pores (nm or nanometer) porous near insulat\$3 and cyclic siloxane	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	WITH	ON	2008/12/20 20:02
L14	219	pores (nm or nanometer) and cyclic siloxane	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	WITH	ON	2008/12/20 20:02
L15	113	pores (nm or nanometer) and cyclic siloxane and vinyl	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	WITH	ON	2008/12/20 20:08
L16	47	pores (nm or nanometer) and cyclic siloxane and vinyl and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	WITH	ON	2008/12/20 20:09
L17	7	"375516".ap.	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/20 20:15
L18	1	"20040137243"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/20 20:47
L19	35	cyclic near(organic adj silica or siloxane) pores	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2008/12/20 20:56
L20	1	"20070093078"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2008/12/20 21:15
L21	993	438/200.ccls.	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2008/12/20 21:51
L22	3007	438/680,778.ccls.	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2008/12/20 21:51
L23	2	porous adj insulat\$3 and NEC Corp	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/20 21:52
L24	0	porous and siloxane with cyclic and NEC Corp	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/20 21:53
L25	0	siloxane with cyclic and NEC Corp	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/20 21:53
L26	24	siloxane and NEC Corp	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/20 21:53
L27	9	harada-yoshimichi.in.	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/20 21:53

L28	13	hayashi-yoshiro.in.	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/20 21:54
L29	0	itoh-fuminoro.in.	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/20 21:55
L30	1	hijoka-kenichiro.in.	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/20 21:55
L31	9	takeuchi-tsuneo.in.	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/20 21:55
S1	6	"580606".ap.	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/09/09 12:36
S2	2	"20040166240"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/09/09 13:19
S3	1	"20040253777"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/09/09 13:55
S4	6	"2004008517"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/09 13:57
S5	4	"2004047873"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/09 13:58
S6	3	"20050267253"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/09 14:11
S7	6	"580606".ap.	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/16 13:32
S8	2	"2002118169"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/16 13:50
S9	2	"2001326222"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/16 13:55

S10	2	"20020155639"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/16 13:55
S11	2	"20070093078"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/16 15:12
S12	781	257/e21.261.ccls.	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/16 18:30
S13	6	rare adj gas and 257/e21.261.ccls.	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/16 18:32
S14	7	("4222792" "5003178" "5306739" "5376586" "5989983" "6132814").PN. OR ("6746969"). URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2008/12/16 18:35
S15	8982	(rare or inert)adj gas with mixture and (silane or siloxane) (porous or poros\$3)adj (insulat\$3 or dielectric or ILD or SICOH)	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/16 18:37
S16	94	(rare or inert)adj gas with mixture and (silane or siloxane) (porous or poros\$3)adj (insulat\$3 or dielectric or ILD or SICOH)	US-PGPUB; USPAT; USOCR; FPRS	AND	ON	2008/12/16 18:38
S17	3793	raman spectrum	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/16 18:46
S18	12	(US-20040166240-\$ or US- 20040253777-\$ or US-20050267253- \$ or US-20020155639-\$ or US- 20070100109-\$ or US-20050260420- \$ or US-20050258542-\$ or US- 20050245096-\$ or US-20040069410- \$).did. or (US-7307343-\$).did. or (JP-2004047873-\$).did. or (WO- 2004008517-\$).did.	US-PGPUB; USPAT; JPO; DERWENT	OR	ON	2008/12/16 18:46
S19	0	raman spectrum and S18	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/16 18:46
S20	105	raman spectrum and cycl\$2 and silicon same carbon same oxygen same hydrogen	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/16 18:47
S21	1	raman spectrum and silica skeleton and silicon same carbon same oxygen same hydrogen	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/16 18:50
S22	87	raman spectrum and silica and silicon same carbon same oxygen same hydrogen	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/16 18:50
S23	2881	(porous or poros\$3)near3 (insulat\$3 or dielectric) pores	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2008/12/19 21:00

S24	1772	(porous or poros\$3)near3 (insulat\$3 or dielectric) pores	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:01
S25	176	(porous or poros\$3)near3 (insulat\$3 or dielectric) pores diameter	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:01
S26	0	(porous or poros\$3)near3 (insulat\$3 or dielectric) pores diameterand @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:02
S27	137	(porous or poros\$3)near3 (insulat\$3 or dielectric) pores diameter and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:02
S28	0	(porous or poros\$3)near3 (insulat\$3 or dielectric) pores diameter and trivinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:06
S29	0	(porous or poros\$3)near3 (insulat\$3 or dielectric) pores diameter and tri-vinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:06
S30	15	(porous or poros\$3)near3 (insulat\$3 or dielectric) pores diameter and siloxane and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:06
S31	0	tri-vinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:07
S32	0	trivinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:07
S33	212	tetravinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:08
S34	37	porous and tetravinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:08
S35	3	porous and pores and diameter and tetravinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:08
S36	5	porous and pores and tetravinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:08
S37	37	porous and tetravinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:09
S38	61	(insulat\$3 or dielectric)and tetravinyltetramethylcyclo\$13 and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:10
S39	86	(insulat\$3 or dielectric)and Si C H O ratio and @ad<"20041129"	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/19 21:10
S40	0	wo "2003019645"	US-PGPUB; USPAT; USOCR; FPRS	NEAR	ON	2008/12/19 21:43

S41	1	wo "2003019645"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2008/12/19 21:43
S42	2	wo "2003005429"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2008/12/19 21:43
S43	70	hydrogenated silicon oxycarbide and ("o.sub.2" or oxygen or oxidizer) and (He or Ne or Ar or Kr)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2008/12/19 22:31
S44	151	("4842888" "4981724" "5156881" "5182000" "5208069" "5284730" "5364666" "5465680" "5525550" "5530581" "5599740" "5800877" "5874367"). PN. OR ("6159871").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2008/12/19 22:43
S45	2	tvmtcto	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/19 22:45
S46	10192	raman adj spectr\$6	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/19 22:47
S47	2	raman adj spectr\$6 and (hydrogenated silicon oxycarbide or SiOCH)	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/19 22:48
S48	2	raman adj spectr\$6 and (hydrogenated silicon oxycarbide or SiOCH or H:siO)	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/19 22:48
S49	2	raman adj spectr\$6 and (hydrogenated silicon oxycarbide or SiOCH or H:siOC)	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/19 22:48
S50	112	spectr\$6 and (hydrogenated silicon oxycarbide or SiOCH or H:siOC)	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2008/12/19 22:49
S51	9	(O/Si C/si H/Si)	US-PGPUB; USPAT; USOCR; FPRS	WITH	ON	2008/12/20 14:22
S52	23	(O/Si C/si H/Si)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2008/12/20 14:24
S53	26	(O/Si C/si H/Si)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2008/12/20 14:25

S54	23	(US-20040166240-\$ or US-20040253777-\$ or US-20050267253-\$ or US-20020155639-\$ or US-20070100109-\$ or US-20050260420-\$ or US-20050258542-\$ or US-20050245096-\$ or US-20040069410-\$ or US-20060157798-\$ or US-20060148252-\$ or US-20070098890-\$ or US-20060255466-\$ or US-20060158101-\$ or US-20050006665-\$ or US-20040197474-\$ or US-20040183162-\$).did. or (US-7307343-\$ or US-6846756-\$ or US-6772710-\$).did. or (JP-2004047873-\$).did. or (WO-2004008517-\$ or WO-03005429-\$).did.	US-PGPUB; USPAT; JPO; DERWENT	OR	ON	2008/12/20 14:28
S55	12	pores and S54	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2008/12/20 14:28

12/20/2008 9:59:33 PM

C:\Documents and Settings\lcrawford\My Documents\EAST\Workspaces\10580606.wsp